

What is a Semiconductor?

A **semiconductor** material has an electrical conductivity value falling between that of a conductor, such as metallic copper, and an insulator, such as glass. Its conductivity falls in its temperature range, usually between in the opposite way. Its **conducting** properties may be altered in useful ways by introducing impurities ("doping") into its crystal structure. When two differently doped regions exist in the same crystal, a semiconductor junction is created. The behavior of charge carriers, which include electrons, ions, and electron holes, at these junctions is the basis of diodes, transistors, and many modern electronic devices. Some examples of semiconductors are silicon, germanium, gallium arsenide, and elements near the so-called "metalloid staircase" on the periodic table. When silicon, gallium arsenide is the second-most common semiconductor and is used in most diodes, solar cells, microwave-frequency integrated circuits, and others. Silicon is a critical element for fabricating most electronic circuits.

Semiconductor devices can display a range of useful properties, such as allowing current to flow easily in one direction than the other, showing variable resistance, and having sensitivity to light or heat. Because the electrical properties of a semiconductor material can be modified by doping, and by the application of electrical fields or light, devices made from semiconductors can be used for amplification, switching, and energy conversion.

The conductivity of silicon is increased by adding a small amount (of the order of 1 in 10⁹) of pentavalent elements, phosphorus, or arsenic to produce *n*-type silicon. Gallium, indium, antimony. This process is known as doping, and the resulting semiconductors are known as doped or extrinsic semiconductors. Apart from doping, the conductivity of a semiconductor can be improved by increasing its temperature. This is contrary to the behavior of a metal, in which conductivity decreases with an increase in temperature.

The modern understanding of the properties of a semiconductor relies on quantum physics to explain the movement of charge carriers in a crystal lattice.^[1] Doping greatly increases the number of charge carriers within the crystal. When a doped semiconductor contains free holes, it is called "p-type", and when it contains free electrons, it is known as "n-type". The semiconductor elements used in electronic devices are doped under precise conditions to control the concentrations and regions of p- and n-type regions. A single semiconductor device crystal can have many p- and n-type regions; the p-n junctions between these regions are responsible for the useful electronic behavior. Using a laser-point probe, one can determine quickly whether a semiconductor sample is p or n-type.^[2]

Some of the properties of semiconductor materials were observed throughout the mid 19th and first decades of the 20th century. The first practical application of semiconductors in electronics, was the 1964 development of the radio-shield detector, a p-n junction diode used in early radio detectors. Developments in quantum physics led to work on the movement of the transistor in 1947,^[3] the integrated circuit in 1958, and the MOSFET (metal-oxide semiconductor field-effect transistor) in 1959.

Properties Of a Semi Conductor

Variable electrical conductivity

Semiconductors in their natural state are poor conductors because a *valence* restricts the flow of electrons, and semiconductors have their valence bands filled, preventing the entire flow of new electrons. Special doped techniques allow semiconducting materials to behave like conducting materials, such as *doping* or *gating*. These modifications have two categories: *n-type* and *p-type*. These refer to the excess or shortage of electrons, respectively. A balanced number of electrons would cause a current to flow throughout the material.[1]

Heterojunctions

Heterojunctions occur when two differently doped semiconducting materials are joined. For example, a configuration could consist of *p-doped* and *n-doped* germanium. This results in an exchange of electrons and holes between the differently doped semiconducting materials. The *n-doped* germanium would have an excess of electrons, and the *p-doped* germanium would have an excess of holes. The transfer occurs until an equilibrium is reached by a process called *diffusion*, which causes the migrating electrons from the *n-type* to come in contact with the migrating holes from the *p-type*. The result of this process is a narrow strip of immobile ions, which causes an electric field across the junction.[1][2]

Excited electrons

A difference in electric potential on a semiconducting material would cause it to leave thermal equilibrium and create a non-equilibrium situation. This involves electrons and holes at the system, which occurs via a process called *photoconductive effect*. Whenever thermal equilibrium is disturbed on a semiconducting material, the number of holes and electrons changes. Such disruptions can occur as a result of a temperature difference or *gating*, which can raise the system and create electrons and holes. The process that creates and stabilizes electrons and holes are called *generation* and *recombination*, respectively.[1]

Light emission

In certain semiconductors, excited electrons can return by emitting light instead of producing heat. [2] These semiconductors are used in the construction of *light emitting diodes* and *transistors* quantum dots.

High thermal conductivity

Semiconductors with high thermal conductivity can be used for heat dissipation and improving thermal management of electronics.

Thermal energy conversion

Semiconductors have large **thermoelectric** power factors making them useful in **thermoelectric** generators, as well as high **thermoelectric** figures of merit making them useful in **thermoelectric** cooling.[3]

Materials

Most of the 120 different semiconductor materials

Silicon crystals are the most common semiconductor materials used in microelectronics and photovoltaics

A large number of elements and compounds have semiconductor properties, including [12]

- Certain pure elements are found in group 14 of the periodic table. The most commercially important of these elements are silicon and germanium. Tellurium and selenium are used less effectively because they have 4 valence electrons in their outermost shell, which gives them the ability to gain or lose electrons equally in the same way.
- Binary compounds, particularly between elements in groups 12 and 16, such as gallium, arsenic, groups 13 and 16, groups 14 and 16, and between different group 14 elements, e.g. silicon carbide.
- Certain binary compounds, oxides, and alloys.
- Organic semiconductor, such as organic compounds.
- Semiconductor metal-organic frameworks (MOFs)

The most common semiconductor materials are crystalline solids, but amorphous and liquid semiconductors are also known. These include hydrogenated amorphous silicon and solutions of silicon, selenium, and tellurium in a variety of proportions. These compounds share with known semiconductors the properties of immediate conductivity and a rapid variation of conductivity with temperature, as well as occasional optical properties. Such disordered materials lack the tight crystalline structure of conventional semiconductors such as silicon. They have generally used in thin-film structures, which do not require material of higher electronic quality, being relatively insensitive to impurities and radiation damage.

Preparation of semiconductor materials

Almost all of today's electronic technology involves the use of semiconductors, with the most important ones being the integrated circuit (IC), which are found in desktop, laptop, wireless, cell phones, and other electronic devices. Semiconductors for ICs are manufactured by using an ideal semiconductor material, chemical purity is paramount. Any small imperfections can have a drastic effect on how the semiconductor material behaves due to the scale at which the materials are used [13].

A high degree of crystalline perfection is also required. Many faults in the crystal structure (such as dislocations, voids, and grain boundaries) interfere with the semiconductor properties of the material. Crystalline faults are a major cause of defective semiconductor devices. The larger the crystal, the more difficult it is to achieve the necessary perfection. Current mass production processes for crystal begin between 100 and 300 mm (3.9 and 11.8 in) in diameter, grown as cylinders and sliced into wafers.

There is a continuous effort to develop new ways to prepare semiconductor materials for ICs. One process is called *thermal oxidation*, which forms silicon dioxide on the surface of the silicon. This is used as a gate insulator and field oxide. Other processes are called *photolithography* and *photocopying*. This process is what creates the patterns on the silicon in the integrated circuit.



CENTRAL
TRANSISTOR
CORPORATION

LOW NOISE ZENER DIODE
0.5 VOLT TO 10 VOLT
50% TOLERENCE



800-00 CASE

CentralTM
Semiconductor Corp.

DESCRIPTION

The CENTRAL SEMICONDUCTOR CORP. 800 series types are high quality Silicon Zener Diodes designed for low leakage, low current precision voltage applications.

NOTE: For lower voltage devices, see CORP. 200 series.

MAXIMUM RATINGS

Power Dissipation (at T_{Amax}) 200 mW
Operating and Storage Temperature

SYMBOLS



800

40 to +100

0 to 75

ELECTRICAL CHARACTERISTICS: T_{Amax} type 200 and 800; T_{Amin} for all types

Part	ZENER VOLTAGE			ZENER CURRENT	ZENER VOLTAGE	ZENER VOLTAGE		ZENER VOLTAGE	ZENER VOLTAGE
	V _Z					V _Z			
	50	100	500	10	50	100	500	10	50
800-001	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-002	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-003	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-004	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-005	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-006	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-007	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-008	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-009	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-010	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-011	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-012	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-013	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-014	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-015	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-016	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-017	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-018	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-019	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-020	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-021	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-022	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-023	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-024	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-025	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-026	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-027	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-028	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-029	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50
800-030	0.50	0.50	0.50	10	0.50	0.50	0.50	0.50	0.50

Available in special order only. See our catalog for details.

What is a Semiconductor?

A **semiconductor** material has an electrical conductivity value falling between that of a conductor, such as metallic copper, and an insulator, such as glass. Its conductivity falls in its intermediate class, usually between the square root to its **conducting** properties may be altered in useful ways by introducing impurities ("doping") into its crystal structure. When two differently doped regions join in the same crystal, a semiconductor junction is created. The behavior of charge carriers, which include electrons, ions, and electron holes, at these junctions is the basis of diodes, transistors, and many modern electronic devices. Some examples of semiconductors are silicon, germanium, gallium arsenide, and elements near the so-called "metalloid staircase" on the periodic table. When silicon, gallium arsenide is the second-most common semiconductor and is used in most diodes, solar cells, microwave-frequency integrated circuits, and others. Silicon is a critical element for fabricating most electronic circuits.

Semiconductor devices can display a range of useful properties, such as allowing current to flow easily in one direction than the other, showing variable resistance, and having sensitivity to light or heat. Because the electrical properties of a semiconductor material can be modified by doping, and by the application of electrical fields or light, devices made from semiconductors can be used for amplification, switching, and energy conversion.

The conductivity of silicon is increased by adding a small amount (of the order of 1 in 10⁹) of pentavalent elements, phosphorus, or arsenic to produce *n*-type silicon. Gallium, indium, antimony. This process is known as doping, and the resulting semiconductors are known as *doped* or *extrinsic* semiconductors. Apart from doping, the conductivity of a semiconductor can be improved by increasing its temperature. This is contrary to the behavior of a metal, in which conductivity decreases with an increase in temperature.

The modern understanding of the properties of a semiconductor relies on quantum physics to explain the movement of charge carriers in a crystal lattice.[1] Doping greatly increases the number of charge carriers within the crystal. When a doped semiconductor contains free holes, it is called "p-type", and when it contains free electrons, it is known as "n-type". The semiconductor elements used in electronic devices are doped under precise conditions to control the concentrations and regions of p- and n-type regions. A single semiconductor device crystal can have many p- and n-type regions; the p-n junctions between these regions are responsible for the useful electronic behavior. Using a laser-point probe, one can determine quickly whether a semiconductor sample is p or n-type.[2]

Some of the properties of semiconductor materials were observed throughout the mid 19th and first decades of the 20th century. The first practical application of semiconductors in electronics, was the 1964 development of the *valley electron device*, a primitive semiconductor diode used in early radio receivers. Developments in quantum physics led to work on the movement of the transistor in 1947,[3] the integrated circuit in 1958, and the MOSFET (metal-oxide semiconductor field-effect transistor) in 1959.

Properties Of a Semi Conductor

Variable electrical conductivity

Semiconductors in their natural state are poor conductors because a *valence* restricts the flow of electrons, and semiconductors have their valence bands filled, preventing the entire flow of new electrons. Special doped techniques allow semiconducting materials to behave like conducting materials, such as *doping* or *gating*. These modifications have two categories: *n-type* and *p-type*. These refer to the excess or shortage of electrons, respectively. A balanced number of electrons would cause a current to flow throughout the material.[1]

Heterojunctions

Heterojunctions occur when two differently doped semiconducting materials are joined. For example, a configuration could consist of *p-doped* and *n-doped* germanium. This results in an exchange of electrons and holes between the differently doped semiconducting materials. The *n-doped* germanium would have an excess of electrons, and the *p-doped* germanium would have an excess of holes. The transfer occurs until an equilibrium is reached by a process called *diffusion*, which causes the migrating electrons from the *n-type* to come in contact with the migrating holes from the *p-type*. The result of this process is a narrow strip of immobile ions, which causes an electric field across the junction.[1][2]

Excited electrons

A difference in electric potential on a semiconducting material would cause it to leave thermal equilibrium and create a non-equilibrium situation. This involves electrons and holes at the system, which occurs via a process called *photoconductive effect*. Whenever thermal equilibrium is disturbed on a semiconducting material, the number of holes and electrons changes. Such disruptions can occur as a result of a temperature difference or *gating*, which can raise the system and create electrons and holes. The process that creates and stabilizes electrons and holes are called *generation* and *recombination*, respectively.[1]

Light emission

In certain semiconductors, excited electrons can return to ground by emitting light instead of producing heat. [2] These semiconductors are used in the construction of *light emitting diodes* and *transistors* quantum dots.

High thermal conductivity

Semiconductors with high thermal conductivity can be used for heat dissipation and improving thermal management of electronics.

Thermal energy conversion

Semiconductors have large **thermoelectric** power factors making them useful in **thermoelectric** generators, as well as high **thermoelectric** figures of merit making them useful in **thermoelectric** cooling.[3]

Materials

Most of the 120 different semiconductor materials

Silicon crystals are the most common semiconductor materials used in microelectronics and photovoltaics

A large number of elements and compounds have semiconductor properties, including [12]

- Certain pure elements are found in group 14 of the periodic table. The most commercially important of these elements are silicon and germanium. Gallium and arsenic are used less effectively because they have 4 valence electrons in their outermost shell, which gives them the ability to gain or lose electrons equally in the same way.
- Binary compounds, particularly between elements in groups 13 and 15, such as gallium, arsenic, groups 11 and 16, groups 14 and 16, and between different group 14 elements, e.g. silicon carbide.
- Certain binary compounds, oxides, and alloys.
- Organic semiconductor, such as organic compounds.
- Semiconductor metal-organic frameworks (MOFs)

The most common semiconductor materials are crystalline solids, but amorphous and liquid semiconductors are also known. These include hydrogenated amorphous silicon and solutions of silicon, selenium, and tellurium in a variety of proportions. These compounds share with binary known semiconductors the properties of immediate conductivity and a rapid variation of conductivity with temperature, as well as occasional optical properties. Such disordered materials lack the tight crystalline structure of conventional semiconductors such as silicon. They have generally used in thin-film structures, which do not require material of higher electronic quality, being relatively insensitive to impurities and radiation damage.

Preparation of semiconductor materials

Almost all of today's electronic technology involves the use of semiconductors, with the most important ones being the integrated circuit (IC), which are found in desktop, laptop, wireless, cell phones, and other electronic devices. Semiconductors for ICs are manufactured by using an ideal semiconductor material, chemical purity is paramount. Any small imperfections can have a drastic effect on how the semiconductor behaves due to the scale at which the materials are used [13].

A high degree of crystalline perfection is also required. Many faults in the crystal structure (such as dislocations, voids, and grain boundaries) interfere with the semiconductor properties of the material. Crystalline faults are a major cause of defective semiconductor devices. The larger the crystal, the more difficult it is to achieve the necessary perfection. Current mass production processes for crystal begin between 100 and 300 mm (3.9 and 11.8 in) in diameter, grown as cylinders and sliced into wafers.

There is a continuous of processes that are used to prepare semiconductor materials for ICs. The process is called thermal oxidation, which forms silicon dioxide on the surface of the silicon. This is used as a gate insulator and field oxide. Other processes are called phosphorus and phosphorography. This process is what creates the patterns on the silicon in the integrated circuit.